

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Takeshita et al.
Appl. No. : 10/580,768
Filed : May 25, 2006
For : **POSITIVE RESIST
COMPOSITION AND METHOD
FOR FORMING RESIST
PATTERN**
Examiner : Eoff, A.
Group Art Unit : 1795

AMENDMENT AND RESPONSE TO RESTRICTION REQUIREMENT

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

In response to the Restriction Requirement mailed **March 19, 2008**, please consider the following amendments and remarks.

Amendments to the claims are reflected in the listing of claims which begin on page 2 of this paper.

Remarks/Response to restriction requirement begin on page 9 of this paper.